

<b>Notice of References Cited</b>	Application/Control No. 09/932,866	Applicant(s)/Patent Under Reexamination CHAUVEL ET AL.	
	Examiner Hong C Kim	Art Unit 2186	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-6,430,640	08-2002	Lim, Whai	710/200
	B	US-2002/0073282	06-2002	Chauvel et al.	711/122
	C	US-6,266,539	07-2001	Pardo, Teddy	455/556
	D	US-6,199,124	03-2001	Ramakrishnan et al.	710/40
	E	US-6,029,000	02-2000	Woolsey et al.	717/147
	F	US-6,006,303	12-1999	Barnaby et al.	710/244
	G	US-5,940,872	08-1999	Hammond et al.	711/207
	H	US-4,926,313	05-1990	Byers et al.	710/244
	I	US-4,638,426	01-1987	Chang et al.	711/216
	J	US-4,400,771	08-1983	Suzuki et al.	711/151
	K	US-4,009,470	02-1977	Danilenko et al.	711/151
	L	US-			
	M	US-			

**FOREIGN PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	EP 1182559 A1	02-2002	European Patent	D'Inverno et al.	G06F 12/08
	O	EP 1213650 A2	06-2002	European Patent	CHAUVEL et al.	G06F 09/46
	P					
	Q					
	R					
	S					
	T					

**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	
	V	
	W	
	X	

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.